

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Christophe MALEVILLE et al.

Confirmation No.: 6835

Application No.: 10/691,403

Group Art Unit: 2812

Filing Date: October 21, 2003

Examiner:

For: METHOD FOR PRODUCING A HIGH  
QUALITY USEFUL LAYER ON A  
SUBSTRATE

Attorney Docket No.: 4717-11700

SUBMISSION OF REPLACEMENT FORM PTO-1449

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In reviewing the file for the above-referenced application, it was noted that typographical or clerical errors were made on the Form PTO-1449 submitted with the Information Disclosure Statement filed October 21, 2003. Therefore, submitted herewith is a replacement PTO-1449 to correct these errors. The enclosed PTO-1449 merely corrects the typographical and clerical errors, and no new references have been added. It is respectfully requested that the enclosed PTO-1449 be substituted for the PTO-1449 filed on October 21, 2003.

No fee is believed to be due for this response. Should any fees be required, however, please charge such fees to Winston & Strawn LLP Deposit Account No. 50-1814.

Respectfully submitted,

Date

4/28/05

Allan A. Fanucci

(Reg. No. 30,256)

**WINSTON & STRAWN LLP**  
**Customer No. 28765**

212-294-3311

# LIST OF REFERENCES CITED BY APPLICANT

Form PTO-1449

(Use several sheets if necessary)

Sheet 1 of 1

ATTY. DOCKET NO.:

4717-11700

APPLICATION NO.:

10/691,403

APPLICANT:

Christophe MALEVILLE et al.

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October 21, 2003

GROUP:

2812

## U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	CITE NO.	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	AA	6,362,076 B1	03/2002	Inazuki et al.	438	458	
	AB						
	AC						
	AD						
	AE						
	AF						

## FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							YES	NO
	AG	2 797 713	02/2001	France				
	AH							
	AI							

## NON-PATENT DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

	AJ	Aditya Agarwal et al., "Efficient production of silicon-on-insulator films by co-implantation of He <sup>+</sup> with H <sup>+</sup> ," Applied Physics Letters, Vol. 72, pp. 1086-1088 (1998).
	AK	
	AL	
	AM	

EXAMINER

DATE CONSIDERED

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.